

Nishantha Sampath Punchi Hewage

Promoting a Second-Tier Protection Regime for Innovation of Small and Medium-Sized Enterprises in South Asia

The Case of Sri Lanka



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Abbreviations

ACIP	Advisory Council of Intellectual Property
AIPPI	International Association for the Protection of Intellectual Property
ARIPO	African Regional Industrial Property Organization
ASIAN	Association of Southeast Asian Nations
CBD	Convention on Biodiversity
CGPDTM	Controller General of Patents, Designs and Trademarks
DPMA	Deutsches Patent- und Markenamt (German Patent and Trademark Office)
EPC	European Patent Convention
EPO	European Patent Office
EU	European Union
FDI	Foreign Direct Investment
FICCI	Federation of India Chambers of Commerce and Industry
FTC	Foreign Technology Collaboration
GATT	General Agreement on Trade and Tariffs
GDP	Gross Domestic Production
GERD	Gross Expenditure on Research and Development
GNE	Gross National Expenditures
ICT	Information and Communication Technologies
IIC	International Review of Industrial Property & Copyright Law
IIP	Institute of Intellectual Property (Japan)
IP	Intellectual Property
IPAC	Industrial Property Advisory Council
IPC	International Patent Classification
IPO	The Intellectual Property Organization of Pakistan
IPR	Intellectual Property Rights
IPRIA	Intellectual Property Research Institute of Australia
ISA	International Search Authorities
ISIC	International Standard Industrial Classification
ISR	International Search Report

Abbreviations

JIPA	Japan Intellectual Property Association
JPO	Japan Patent Office
KIPI	Kenya Intellectual Property Institute
KIPO	Korean Intellectual Property Office
MNCs	Multinational Corporations
MyIPO	Intellectual Property Cooperation of Malaysia
NGO	Non Governmental Organization
NIPO	National Intellectual Property Office of Sri Lanka
NLR	New Law Reports (Sri Lanka)
NSF	National Science Foundation
OAPI	African Intellectual Property Organisation
OECD	Organisation for Economic Co-operation and Development
PCT	Patent Cooperation Treaty
SIPO	State Intellectual Property Office of People's Republic of China
SMEs	Small and Medium Sized Enterprises
SMMEs	Small, Medium and Micro Enterprises
Sri LR	Sri Lanka Law Reports
STP	Second-Tier Protection
TK	Traditional Knowledge
TKDL	Traditional Knowledge Digital Library
TRIPS	Trade Related Aspects of Intellectual Property Rights
UNIDO	United Nations Industrial Development Organization
UM	Utility Models
UI	Utility Innovations
US	United States
WIPO	World Intellectual Property Organization
WTO	World Trade Organization